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L	APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
_	10/717,128	11/19/2003	James Mac Freitag	HIT1P027/HSJ9-2003-0150U	S 7028	
	50535 ZILKA-KOTA	7590 02/22/200 B, PC	7	EXAM	EXAMINER	
	P.O. BOX 7211	120		CHEN,	CHEN, BRET P	
SAN JOSE, CA 95172-1120				ART UNIT	PAPER NUMBER	
				1762		
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	SHORTENED STATUTOR	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE  PAPER		
	3 MO	NTHS	02/22/2007			

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

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	Application No.	Applicant(s)				
	10/717,128	FREITAG ET AL.				
Office Action Summary	Examiner	Art Unit				
·	B. Chen	1762				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet wi	th the correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPL' WHICHEVER IS LONGER, FROM THE MAILING D.  Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNIC 36(a). In no event, however, may a re will apply and will expire SIX (6) MON c, cause the application to become AB	CATION.  sply be timely filed  IHS from the mailing date of this communication.  ANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 13 D	ecember 2006.					
·	action is non-final.					
3) Since this application is in condition for allowar		ers, prosecution as to the merits is				
closed in accordance with the practice under E	•	•				
Disposition of Claims	•					
. 4)⊠ Claim(s) <u>1-19</u> is/are pending in the application.						
	4a) Of the above claim(s) <u>13-15,17 and 18</u> is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-12,16 and 19</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/o	r election requirement.					
Application Papers						
9) The specification is objected to by the Examine	er.					
10) The drawing(s) filed on is/are: a) acc		by the Examiner.				
Applicant may not request that any objection to the		•				
Replacement drawing sheet(s) including the correct	tion is required if the drawing(	s) is objected to. See 37 CFR 1.121(d).				
11)☐ The oath or declaration is objected to by the Ex	caminer. Note the attached	Office Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. §	119(a)-(d) or (f).				
a) ☐ All b) ☐ Some * c) ☐ None of:						
1. Certified copies of the priority document						
2. Certified copies of the priority document	•	·				
3. Copies of the certified copies of the prior		received in this National Stage				
application from the International Bureau  * See the attached detailed Office action for a list		received				
	or the certified copies flot	coerveu.				
Attachment(s)	V					
1) Notice of References Cited (PTO-892)		ummary (PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08)	_	)/Mail Date formal Patent Application				
Paper No(s)/Mail Date	6) Other:	·				

## **DETAILED ACTION**

Claims 1-19 are pending in this application. Amended claims 1, 16, 19 are noted.

The amendment dated 12/13/07 has been entered and carefully considered. In view of said amendment, the 112 rejection has been withdrawn.

Claims 13-15, 17-18 have been withdrawn from consideration as being directed to a nonelected invention.

## Claim Rejections - 35 USC § 103

The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Claims 1-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over

Pinarbasi (6,208,492) in view of Pinarbasi (6,317,299) or Huai et al. (6,381,105). Pinarbasi
'492 discloses a method of forming a magnetic head having a PtMn layer wherein the method
comprises forming a bilayer seedlayer structure 302, forming an AFM layer 214 over the
seedlayer structure, forming an AP layer structure 218/222/220 above the AFM layer, a spacer
layer 212 over the AP structure, and a free layer 202 above the spacer layer (Figure 13). The
AFM layer includes IrMn and PtMn (col.3 lines 56-60) and the various layers are formed using
ion beam deposition (col.6 lines 20-25). The dR can be 4.5% (col.3 lines 1-32), the However,
the reference fails to specifically teach forming a PtMn layer using ion beam deposition.

It is noted above that the reference clearly teaches that various layers can be formed by ion beam deposition. One skilled in the art would realize that the reference suggests that the PtMn layer could be deposited by ion beam deposition. It would have been obvious to one

Application/Control Number: 10/717,128

Art Unit: 1762

skilled in the art to deposit the PtMn layer by ion beam deposition given the teaching of Pinarbasi '492 that various layers can be formed by ion beam deposition.

In addition, Pinarbasi '299 teaches that PtMn materials can be deposited by ion beam deposition in spin valve sensors (col.6 lines 30-40) and Huai teaches that the antiferromagnetic layer such as PtMn (col.8 lines 59-63) can be deposited by ion beam deposition (col.9 lines 8-10). It would have been obvious to utilize ion beam deposition to deposit the PtMn layer in the process of Pinarbasi '492 with the expectation of success because Pinarbasi '299 and Huai teach the conventionality of using ion beam deposition to form the PtMn layer.

The limitations of claims 2-12 have been addressed above.

Claims 16, 19 are rejected under 35 U.S.C. 103(a) as being unpatentable over

Pinarbasi (6,208,492) in view of Pinarbasi (6,317,299) or Huai et al. (6,381,105) and

additionally in view of Deutchman et al. (5,055,318). The combination of Pinarbasi '492,

Pinarbasi '299, and Huai disclose a method of forming a magnetic head having a PtMn layer

wherein the method comprises forming a bilayer seedlayer structure 302, forming an AFM layer

214 over the seedlayer structure by ion beam deposition, forming an AP layer structure

218/222/220 above the AFM layer, a spacer layer 212 over the AP structure, and a free layer 202

above the spacer layer as noted above. However, the references fail to teach using a first and second ion source.

Deutchman teaches of using a dual ion beam process for forming a film onto a substrate with the benefit of reducing the processing temperatures (col.1 lines 10-14). One ion beam source 20 focuses on the substrate 16 while the second ion beam source 26 focuses on the target

Application/Control Number: 10/717,128

Art Unit: 1762

31 (col.3 lines 50-68). In one embodiment, the process can be performed on magnetic heads (col.10 lines 40-68).

It is noted that Deutchman clearly teaches of utilizing a dual ion beam setup to form a magnetic head at lower processing temperatures to obtain many desirable characteristics. It would have been obvious to utilize Deutchman's setup in Pinarbasi's process with the expectation of obtaining lower processing temperatures and other desirable characteristics.

## Response to Arguments

Applicant's arguments with respect to the claims above have been considered but are most in view of the new ground(s) of rejection.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Application/Control Number: 10/717,128 Page 5

Art Unit: 1762

Any inquiry concerning this communication or earlier communications from the examiner should be directed to B. Chen whose telephone number is (571) 272-1417. The examiner can normally be reached on 7:30am - 4:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Timothy Meeks can be reached on (571) 272-1423. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Bc 2/14/07

BRET CHEN
PRIMARY EXAMINER